



THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : **Confirmation No. 9635**  
Satoshi MAEMORI et al. : Docket No. 2001\_1300A  
Serial No. 09/955,111 : Group Art Unit 1752  
Filed September 19, 2001 : Examiner Sin Lee

POSITIVE-WORKING PHOTORESIST  
COMPOSITION AND PHOTSENSITIVE  
MATERIAL USING SAME

PETITION FOR EXTENSION OF TIME

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

Petition hereby is made for a three month extension of time to respond to the communication of  
September 5, 2003.

The fee of \$950.00 is

- (X) submitted herewith.  
( ) to be charged to Deposit Account No. 23-0975. A duplicate copy of this Petition is enclosed.  
( ) Small entity status of this application is established by a Small Entity Status Assertion which  
( ) is enclosed.  
( ) has been previously submitted.

Respectfully submitted,

Satoshi MAEMORI et al.

03/05/2004 HVUONG1 00000149 09955111

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By

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March 4, 2004

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